

ICS 77.040.01
CCS H 17

SN

**INDUSTRY STANDARD OF THE
PEOPLE'S REPUBLIC OF CHINA**

SN/T 1650-2005

**Determination of iron, aluminium, calcium, magnesium, manganese,
zinc, copper, titanium, chromium, nickel, vanadium in metal silicon.
Inductively coupled plasma atomic emission spectrometry**

金属硅中铁、铝、钙、镁、锰、锌、铜、钛、铬、镍、钒含量的测定 电感耦合等
离子体原子发射光谱法

(English Translation)

Issued on: September 30, 2005

Implemented on: May 1, 2006

**Issued by: General Administration of Quality Supervision, Inspection and
Quarantine of the People Republic of China**

Table of Contents

What this standard covers	1
Document data	2
Standards quoted by this document	3

What this standard covers

This standard specifies the inductively coupled plasma atomic emission spectrometry (ICP-AES) Determination of silicon metal iron, aluminum, calcium, magnesium, manganese, zinc, copper, titanium, chromium, nickel, vanadium content approach. This standard applies to metallic silicon iron, aluminum, calcium, magnesium, manganese, zinc, copper, titanium, chromium, nickel, vanadium content.

Document data

International classification (ICS): 77.040.01.

Chinese classification (CCS): H17.

Estimated length of the Chinese original: 9,968 words.

Standards quoted by this document

GB/T 4010; GB/T 6682